

SHIGA7.048APC

10/576405  
JAP2004/015504 29 APR 2006 PATENT

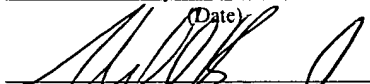
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hada et al.  
Appl. No. : U.S. National Phase of  
PCT/JP2004/015504  
Filed : Herewith  
For : RESIST COMPOSITION AND  
METHOD FOR FORMING  
RESIST PATTERN  
Examiner : Unassigned  
Group Art Unit : Unknown

CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

April 20, 2006

(Date)  
  
Neil S. Bartfield, Ph.D., Reg. No. 39,901

**PRELIMINARY AMENDMENT**

**Mail Stop PCT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Prior to examination of the above-referenced application, please enter the following amendments:

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** begin on page 3 of this paper.

**Remarks** begin on page 5 of this paper.